

C7
32. (Amended) The device according to claim 29, wherein the at least one polycondensate (A) is formed by an arrangement of blocks, said arrangement of blocks being obtained from:

- (1) at least one compound which contains at least two active hydrogen atoms per molecule;
- (2) at least one substance chosen from at least one diol containing at least one acid radical and the salts of said at least one diol; and
- (3) at least one isocyanate chosen from di- and polyisocyanates.

Sub 2
C2
36. (Amended) The device according to claim 29, wherein the at least one polycondensate (A) is formed from at least one additional compound having a silicone skeleton chosen from polysiloxanes, polyalkylsiloxanes and polyarylsiloxanes.

C3
39. (Amended) The device according to claim 29, wherein the at least one polycondensate (A) has a repeating base unit corresponding to the formula I' below:



in which:

- X' is chosen from O and NH,
- B is a hydrocarbon-based radical, this radical being substituted or unsubstituted, and
- R is a divalent radical chosen from aromatic alkylene radicals, C₁ to C₂₀

aliphatic radicals and C₁ to C₂₀ cycloaliphatic radicals, these radicals being substituted or unsubstituted.

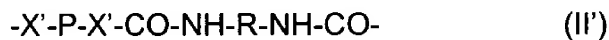
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Sub E3
C4

41. (Amended) The device according to claim 39, wherein the radical R is chosen from hexamethylene, 4,4'-biphenylenemethane, 2,4- and 2,6-tolylene, 1,5-naphthylene, p-phenylene, methylene-4,4-bis-cyclohexyl radicals and divalent radicals derived from isophorone.

42. (Amended) The device according to claim 29, wherein the at least one polycondensate (A) has a repeating base unit corresponding to formula (II'):



in which:

- P is a polysiloxane segment,
- X' is chosen from O and NH, and
- R is a divalent radical chosen from aromatic alkylene radicals, C₁ to C₂₀ aliphatic radicals and C₁ to C₂₀ cycloaliphatic radicals, these radicals being substituted or unsubstituted.

Please add new claims 72-73, as set forth below.

72. (New) The device according to claim 46, wherein R₈ is a lower alkyl radical having 1 to 4 carbon atoms.

73. (New) The device according to claim 46, wherein R₉ is a lower alkyl radical having 1 to 4 carbon atoms.

CS

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